



Synthesis, Characterization, and Performance of Coated Copper Nanoparticles in High Humidity and H₂S Environments

Center 1800:
Material, Physical and
Chemical Sciences



PRESENTED BY

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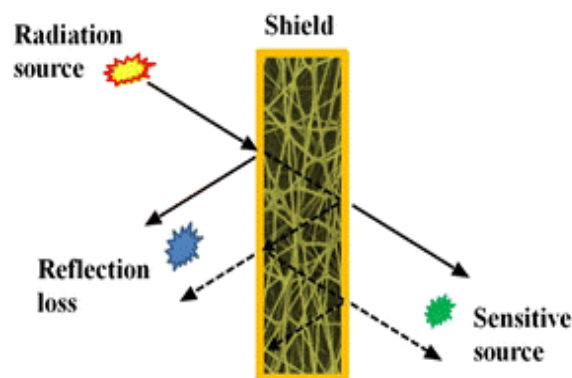
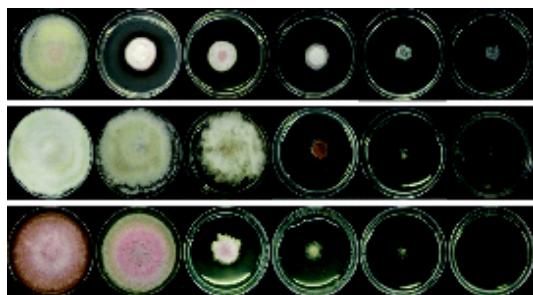
Metal Nanoparticles have Received Great Attention for use in Numerous Applications



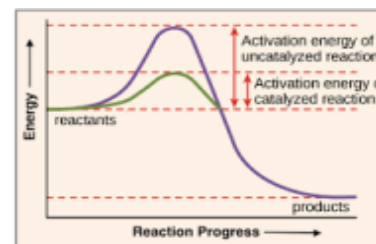
- Coinage metal nanoparticles (NP = Au⁰, Ag⁰, and Cu⁰) have been extensively researched for a wide range of application such as biosensors, optical, solar conversion, lubricants, catalysts, and additive manufacturing [1-2].
- They possess a diverse range of optical, electrical, thermal, antimicrobial, catalytic, magnetic properties that allow them to be deployed across multiple fields.
- In particular, the exceptional electrical properties silver (Ag) and gold (Au) nanoparticles (NPs) have made them the primary choice in electrical applications, but their high cost has led to the search for a more cost-effective alternative.

EMI Shielding Devices

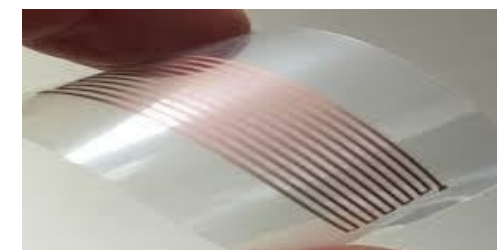
Anti-microbial and Anti-fungal agents



Catalysts

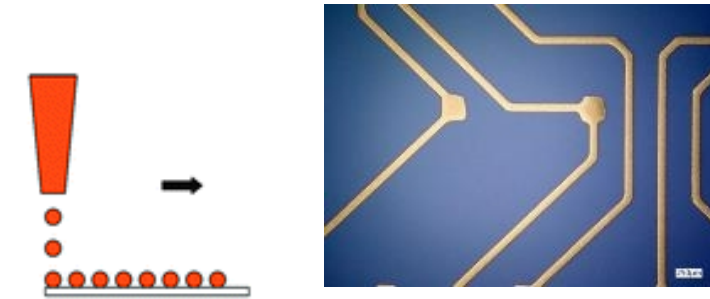


Printed Electronics

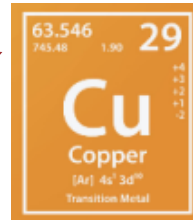


- Intrinsic sensitivity to oxidation under atmospheric conditions
- Susceptible to corrosion

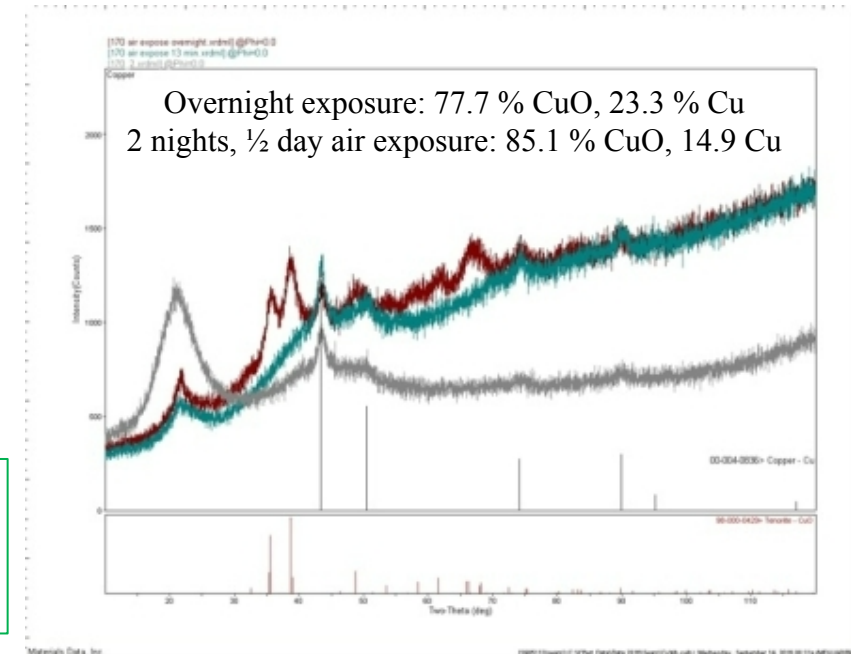
- ## Advantages of Copper?
- Exceptional electrical and thermal conductor
 - Cheaper option compared to other metals, such as gold and silver
 - $\text{Cu} = 0.18 \text{ USD} < \text{Ag} = 23.48 \text{ USD} < \text{Au} = 1962.55 \text{ USD}$ per troy ounce
 - Cu is 130x cheaper than Ag and 11,000x cheaper than Au!



1 H Hydrogen 1.008																	2 He Helium 4.003						
3 Li Lithium 6.94	4 Be Beryllium 9.012																	5 B Boron 10.81	6 C Carbon 12.01	7 N Nitrogen 14.01	8 O Oxygen 16.00	9 F Fluorine 18.99	10 Ne Neon 20.18
11 Na Sodium 22.99	12 Mg Magnesium 24.31																	13 Al Aluminum 26.98	14 Si Silicon 28.09	15 P Phosphorus 30.97	16 S Sulfur 32.06	17 Cl Chlorine 35.45	18 Ar Argon 39.96
19 K Potassium 39.10	20 Ca Calcium 40.08	21 Sc Scandium 44.96	22 Ti Titanium 47.88	23 V Vanadium 50.94	24 Cr Chromium 51.99	25 Mn Manganese 54.94	26 Fe Iron 55.85	27 Co Cobalt 58.93	28 Ni Nickel 58.69	29 Cu Copper 63.54	30 Zn Zinc 65.38	31 Ga Gallium 69.72	32 Ge Germanium 72.64	33 As Arsenic 74.92	34 Se Selenium 78.97	35 Br Bromine 79.90	36 Kr Krypton 83.79						
37 Rb Rubidium 85.46	38 Sr Strontium 87.62	39 Y Yttrium 88.91	40 Zr Zirconium 91.22	41 Nb Niobium 92.91	42 Mo Molybdenum 95.94	43 Tc Technetium 98.91	44 Ru Ruthenium 101.1	45 Rh Rhodium 102.9	46 Pd Palladium 106.4	47 Ag Silver 107.86	48 Cd Cadmium 112.4	49 In Indium 114.8	50 Sn Tin 118.7	51 Sb Antimony 121.75	52 Te Tellurium 127.6	53 I Iodine 126.9	54 Xe Xenon 131.3						
55 Cs Cesium 132.9	56 Ba Barium 137.3	57-70 * Lanthanide series	71 Lu Lutetium 174.96	72 Hf Hafnium 178.4	73 Ta Tantalum 180.94	74 W Tungsten 183.84	75 Re Rhenium 186.21	76 Os Osmium 190.2	77 Ir Iridium 192.22	78 Pt Platinum 195.08	79 Au Gold 196.97	80 Hg Mercury 200.59	81 Tl Thallium 204.38	82 Pb Lead 207.2	83 Bi Bismuth 208.98	84 Po Polonium 209	85 At Astatine 210	86 Rn Radon 222					
87 Fr Francium 223	88 Ra Radium 226	89-102 ** Actinide series	103 La Lanthanum 138.9	104 Ce Cerium 140.1	105 Pr Praseodymium 140.9	106 Nd Neodymium 144.24	107 Pm Promethium 145	108 Sm Samarium 150.36	109 Eu Europium 151.96	110 Gd Gadolinium 157.25	111 Tb Terbium 158.93	112 Dy Dysprosium 162.50	113 Ho Holmium 164.93	114 Er Erbium 167.26	115 Tm Thulium 168.93	116 Yb Ytterbium 173.05	117 Lu Lutetium 175.04	118 Og Oganesson 284					
*Lanthanide series																							
**Actinide series																							



SQ: How can copper oxidation be mitigated?

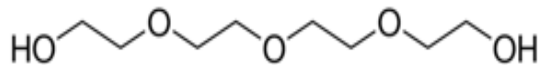
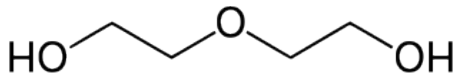
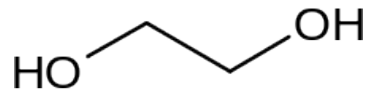


CuO observed as early as overnight exposure to air

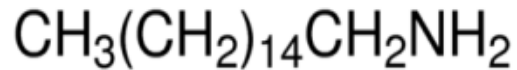
Surface Protection Through the Use of Green Surfactants



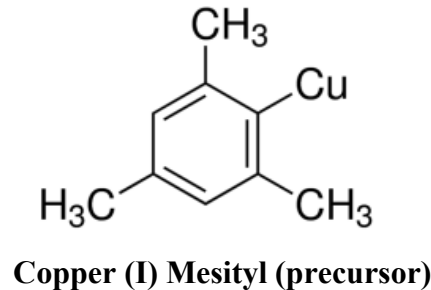
- Several attempts and concepts have been deployed to increase the oxidation resistance of Cu NPs by the addition of various compounds to serve as surfactants.
- Alkylamines (with various lengths), polyols, alkanethiols, allylamine, polyallylamine, and polyvinylpyrrolidone (PVP) have been used in previous research as surfactants for Cu NPs.
- Amine-based ligands such as oleylamine, hexadecylamine, benzotriazole, etc. have high affinity for Cu (111) surfaces and have been shown to provide exceptional oxidation resistance.
- Ligand–NP surface interaction can affect growth rates, morphology, and colloidal stability.
- Glycols preferable because of use as reducing agent, microwave activity, environmentally friendly.



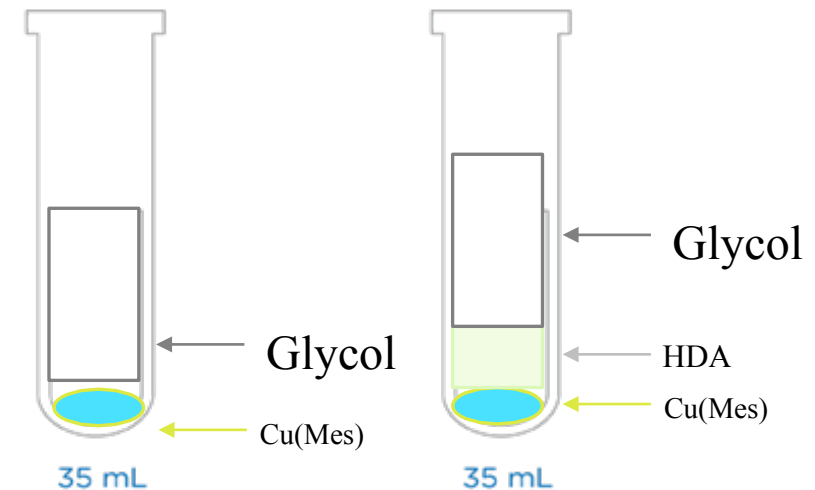
Polyols (solvent)



Hexadecylamine
(surfactant)



Copper (I) Mesityl (precursor)



SQ: How do glycols and amines affect the production and protection of Cu-NPs?

Experimental Flow Chart

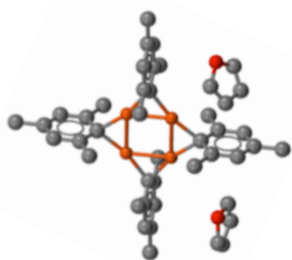


Precursor

- Cu(Mes)*
- Easily decomposable
 - Environmentally friendly



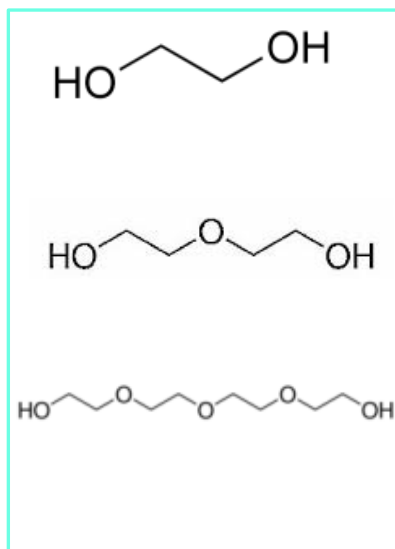
THF



Boyle's Group

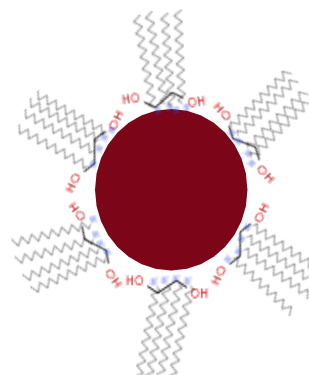
Solvent/ Surfactant

- Polyols*
- Inexpensive
 - Microwave active
 - Reducing agent



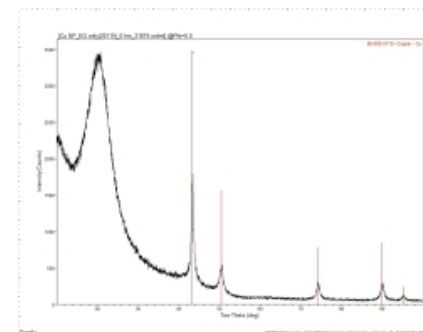
Surfactant

- Provide NP Protection*
- Oxidation resistance
 - Agglomeration
 - Ink performance
 - Conductivity
 - Reproducibility



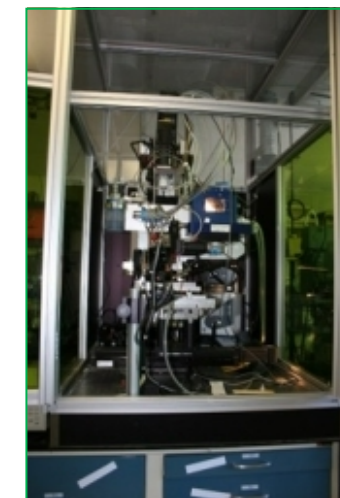
Environmental Testing

- Characterization Techniques (inert vs air)*
- PXRD
 - TEM
 - FTIR
 - TGA
 - FACT-testing (Cl_2 , NO_x .etc)

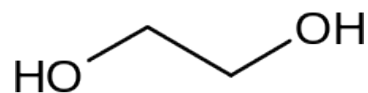
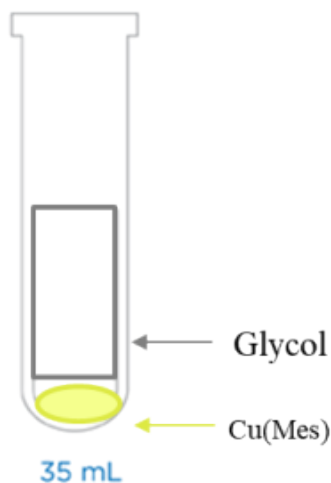
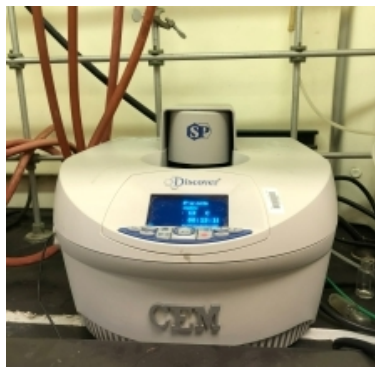


Printing (Future Work)

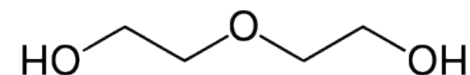
3D printing oxidation resistant nanoparticle



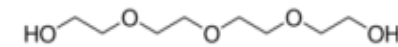
Understanding the Role of the Glycol Reactive Sites/Lengths on Cu-NPs



Ethylene glycol
(EG)



Diethylene glycol
(DEG)



Tetraethylene glycol
(TEG)

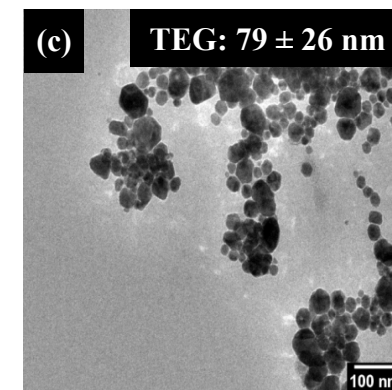
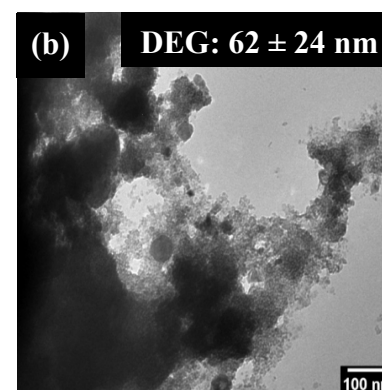
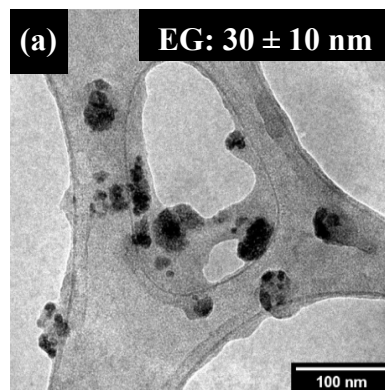
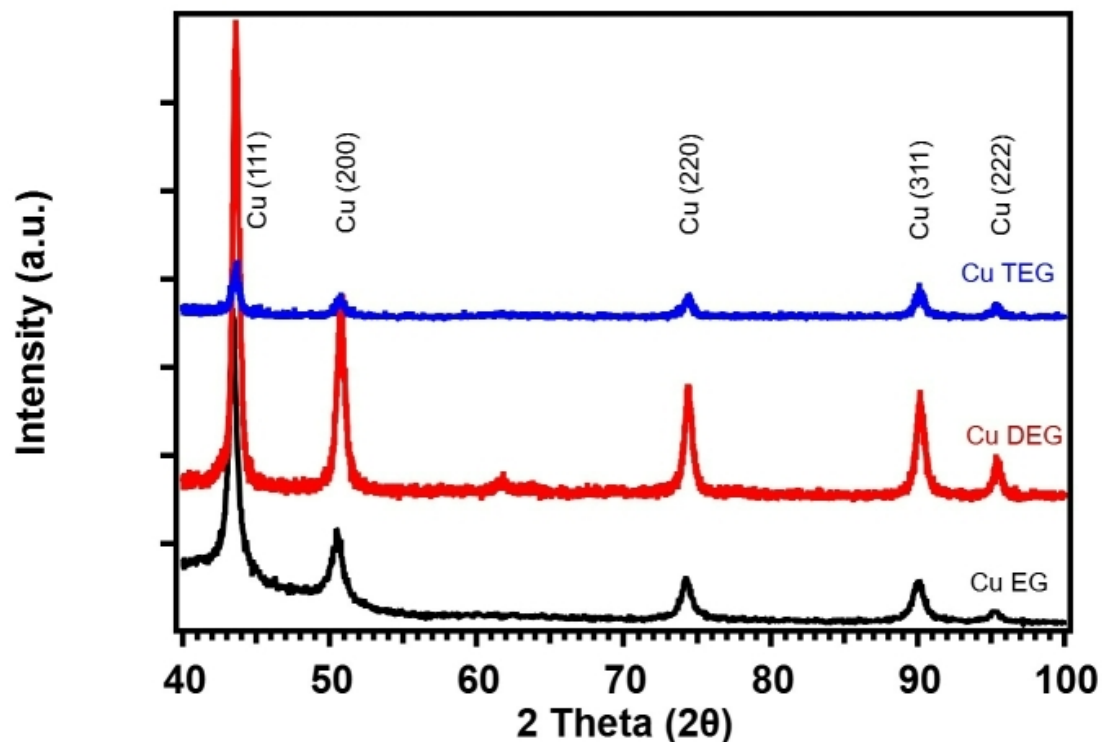
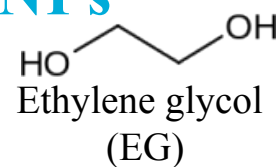
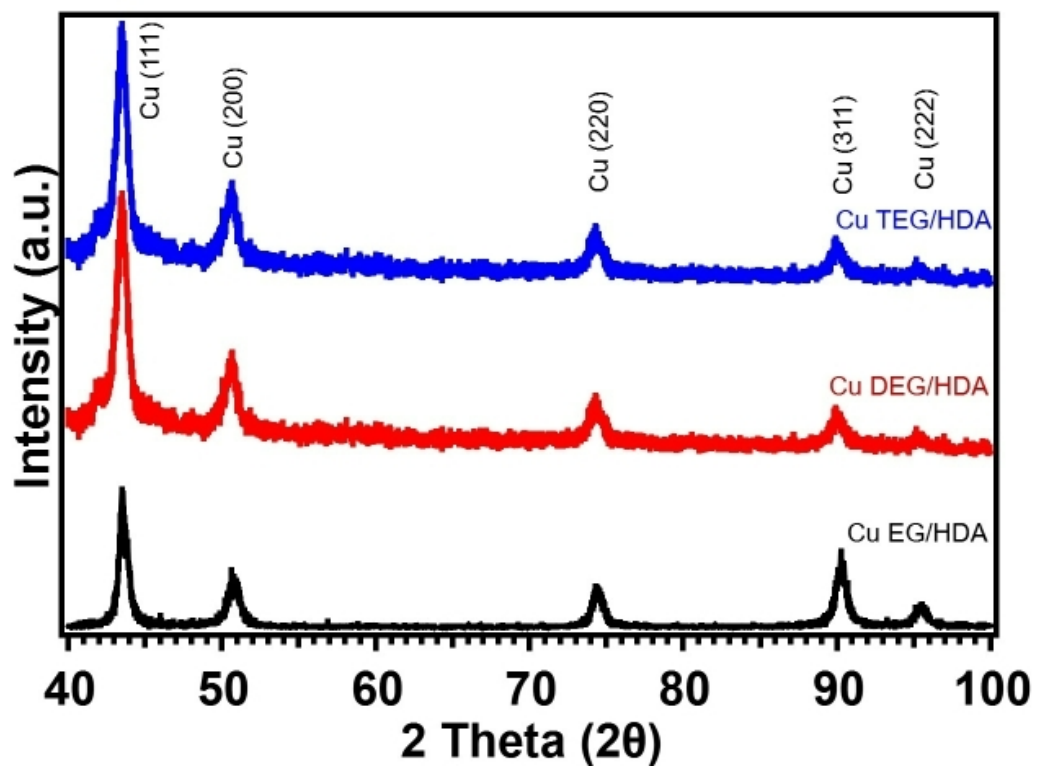
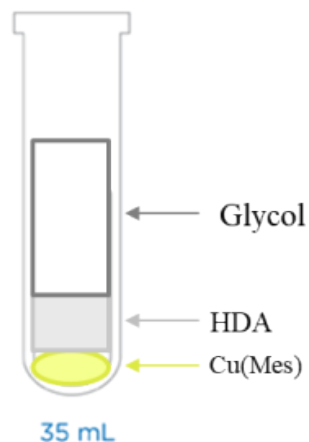
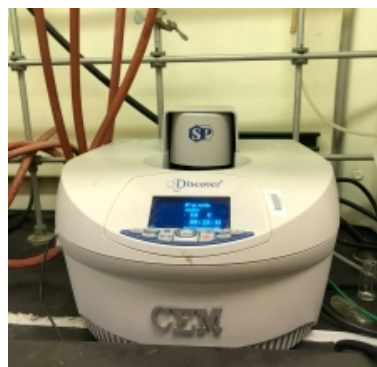


Figure 1. TEM images of Cu NPs synthesized with (a) EG, (b) DEG, and (c) TEG.

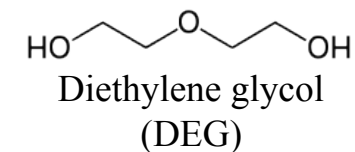
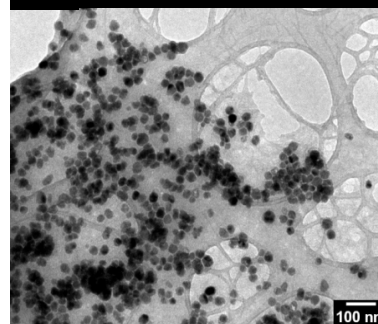


- x Glycol-Cu-NPs exhibit irregular shapes and large size distributions NPs.
- x As the glycol length increases, the particle size and deviation also increase.

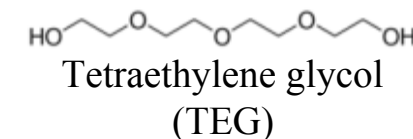
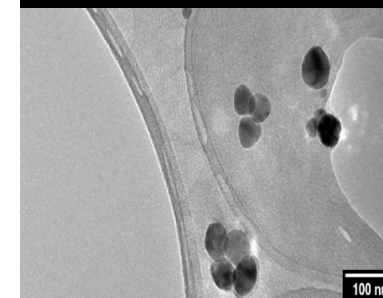
Understanding the Role of the Glycol Reactive Sites/Lengths + HDA on Cu-NPs



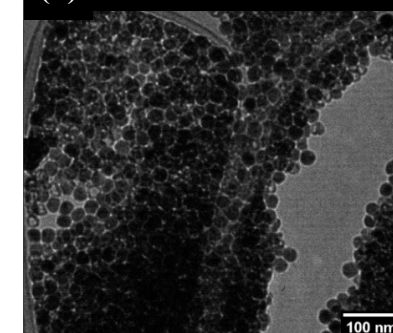
(a) EG/HDA: 10 ± 3 nm



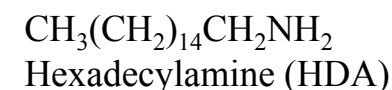
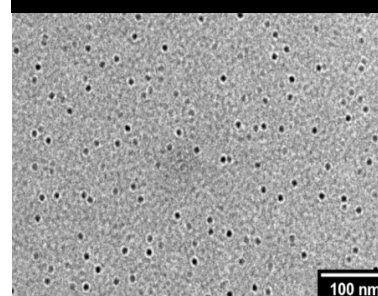
(b) DEG/HDA: 30 ± 5 nm



(d) Cu/HDA: 25 ± 2 nm



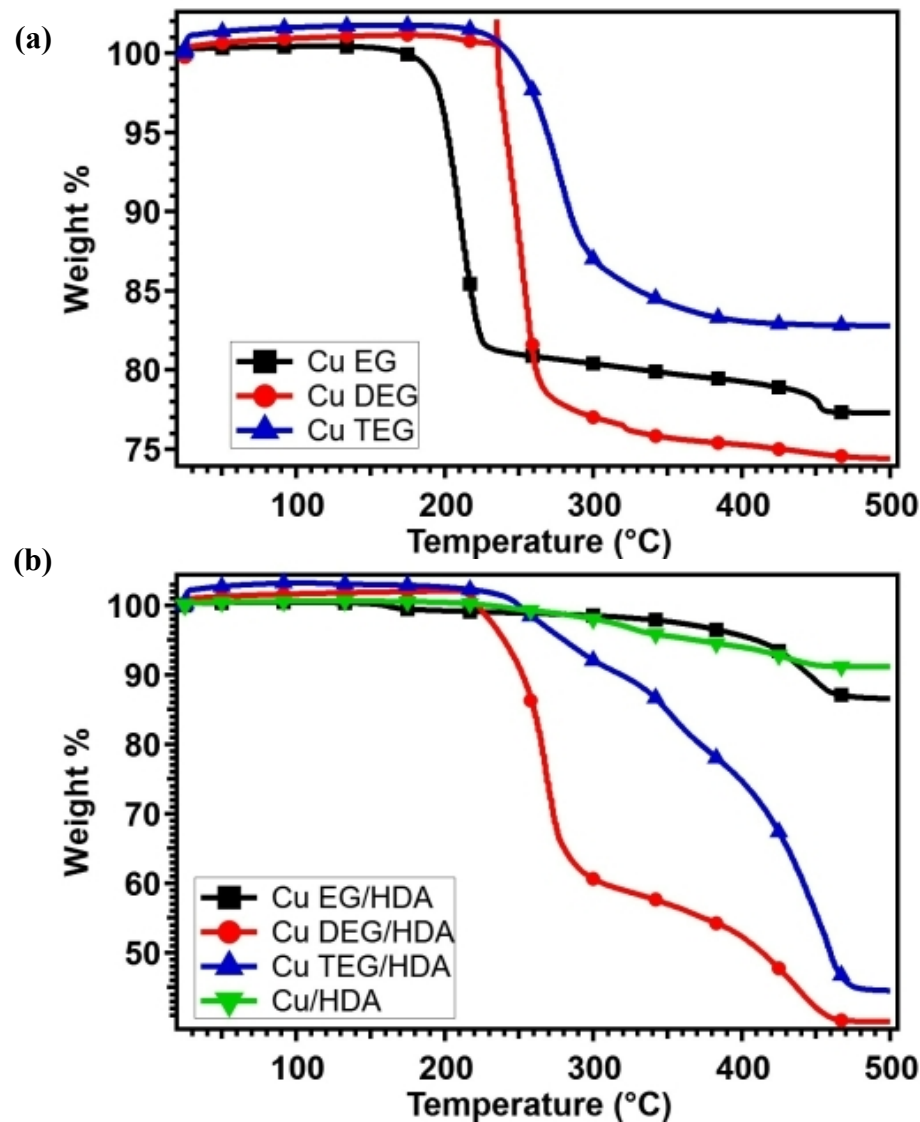
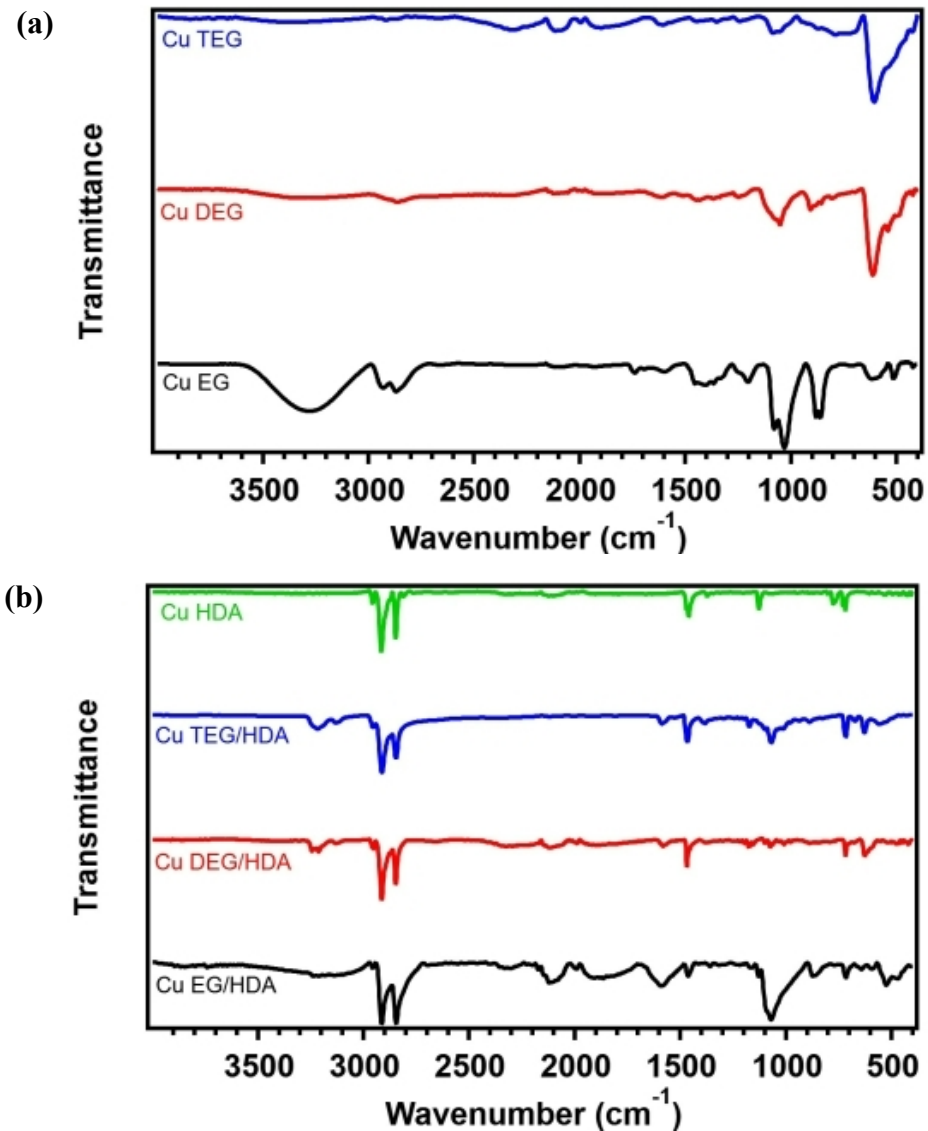
(c) TEG/HDA: 14 ± 2 nm



- ✓ Glycol/HDA-Cu-NPs yielded monodispersed and spherical particles with small size distribution.
- ✓ Amines bind to a specific facet of the Cu-NPs that enable the growth of spherical nanoparticles with or without glycol presence.
- ✓ NPs synthesized with only HDA present also yielded spherical Cu-NPs with small size.

Figure 2. TEM images of Cu NPs synthesized with (a) EG/HDA, (b) DEG/HDA, (c) TEG/HDA, and (d) Cu/HDA

FTIR & TGA of As Synthesized Cu NPs w/wo HDA

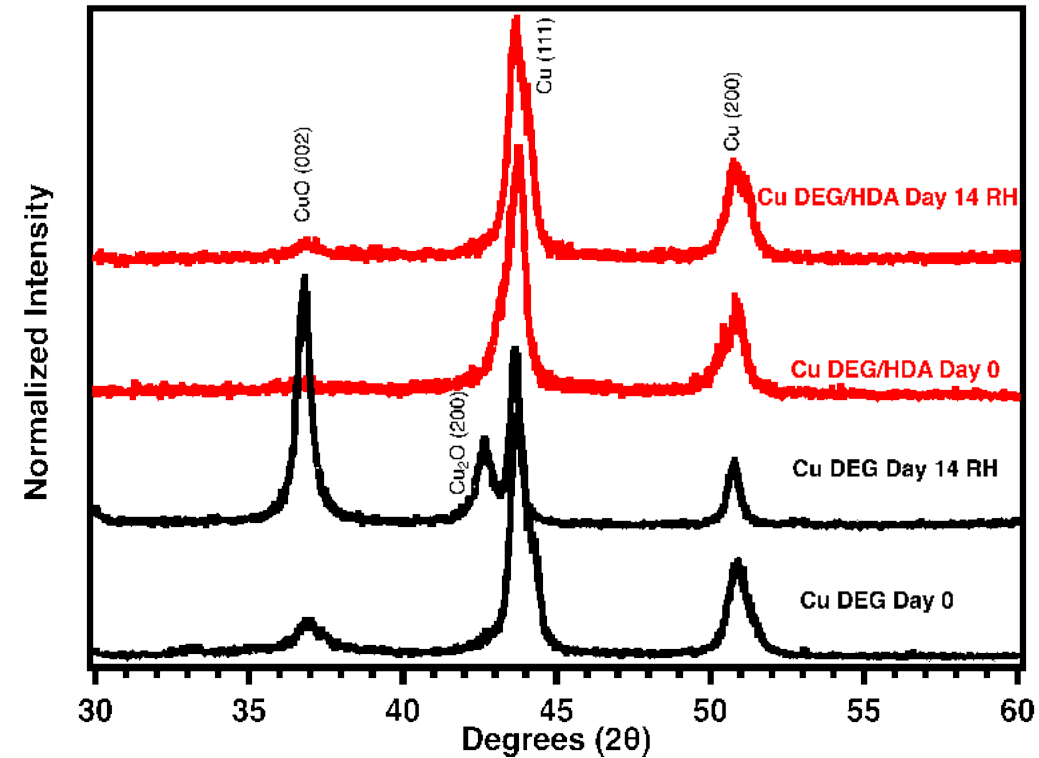


Sample	% Mass Loss
Cu EG	22.72
Cu DEG	25.59
Cu TEG	17.20

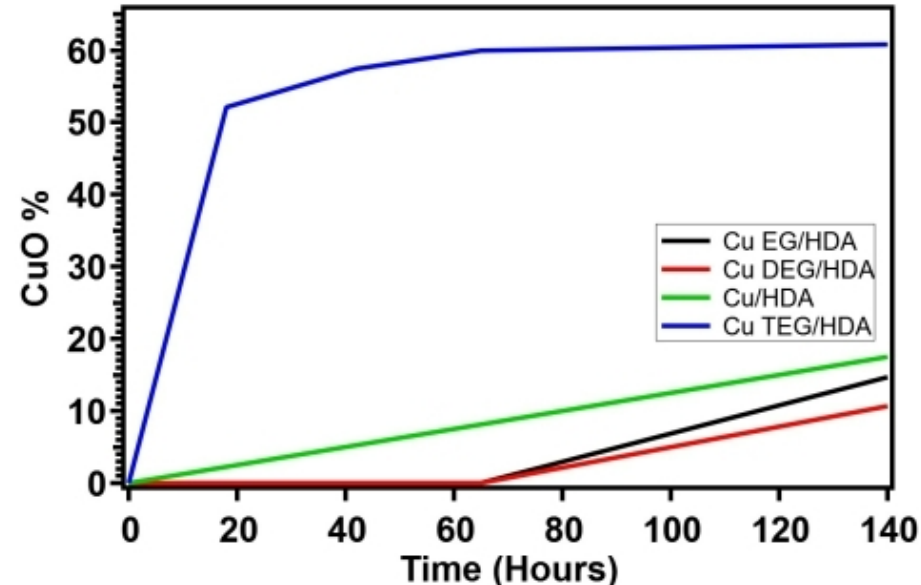
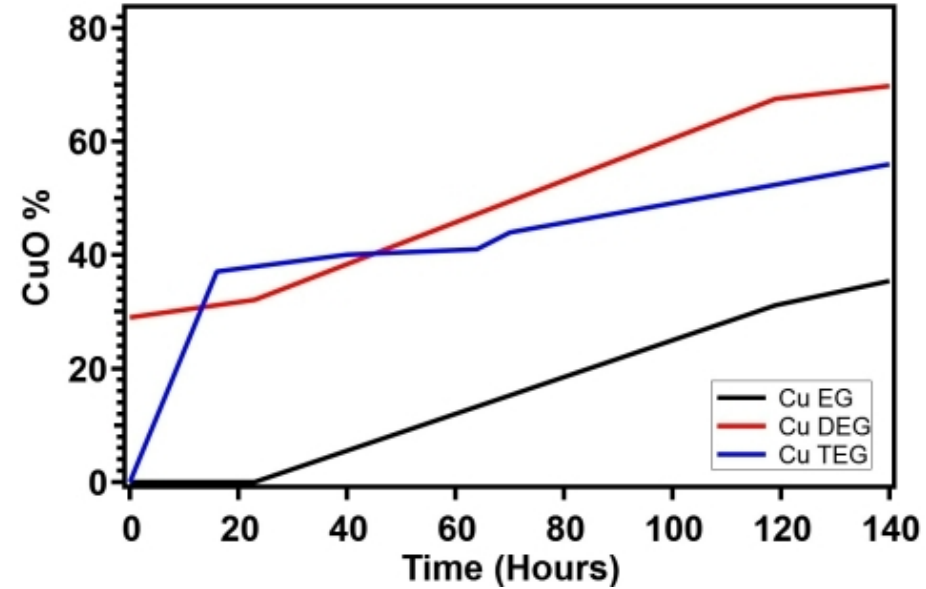
Sample	% Mass Loss
Cu EG/HDA	0.5/12.9
Cu DEG/HDA	36.64/23.26
Cu TEG/HDA	18.46/36.94
Cu/HDA	8.86

Figure 4. TGA spectra of Cu-NPs synthesized with only glycol (a) and Cu-NPs synthesized with glycol and HDA (b).

Cu-NP in 100% RH Environment for 14 Days



- ✓ PXRD indicates that the combination of the glycol and HDA, gives the Cu-NPs much higher resistance to oxidation in high humidity.
- Glycols have exceptional coating performance of Cu-NPs, but their miscibility in water could lead to poor oxidation protection.
- HDA on the other hand is extremely hydrophobic which can prove beneficial in preventing water from reaching the Cu-NP surface.



GES System for Environmental Testing

Periodic DFT for Cu (111) surface, DEG, HDA, and H₂O Interactions



- DEG has a consistent binding energy (BE) with the Cu (111) surface at both concentrations.
- For the HDA, the BE is stronger at higher concentrations (-1.27 eV) and weaker at lower concentrations.
- In solutions where both HDA and DEG molecules are present, initial binding will be between the Cu(111) surface and the HDA up to $\sim 0.1 \text{ \#}/\text{nm}^2$, and then subsequent DEG binding.
- This supports the results from TEM, FTIR, and oxidation studies indicating that for Glycol/HDA-Cu-NPs, binding of HDA first, followed by subsequent binding of the glycol occurs.

Table 1: Binding energy (eV) between the surfactant (HDA or DEG) and the Cu(111) surface

Surfactant	Concentration ($\text{\#}/\text{nm}^2$)	Binding Energy (eV)
		Surfactant to Cu (111)
DEG	0.1	-0.727
	0.2	-0.715
HDA	0.1	-1.273
	0.2	-0.534

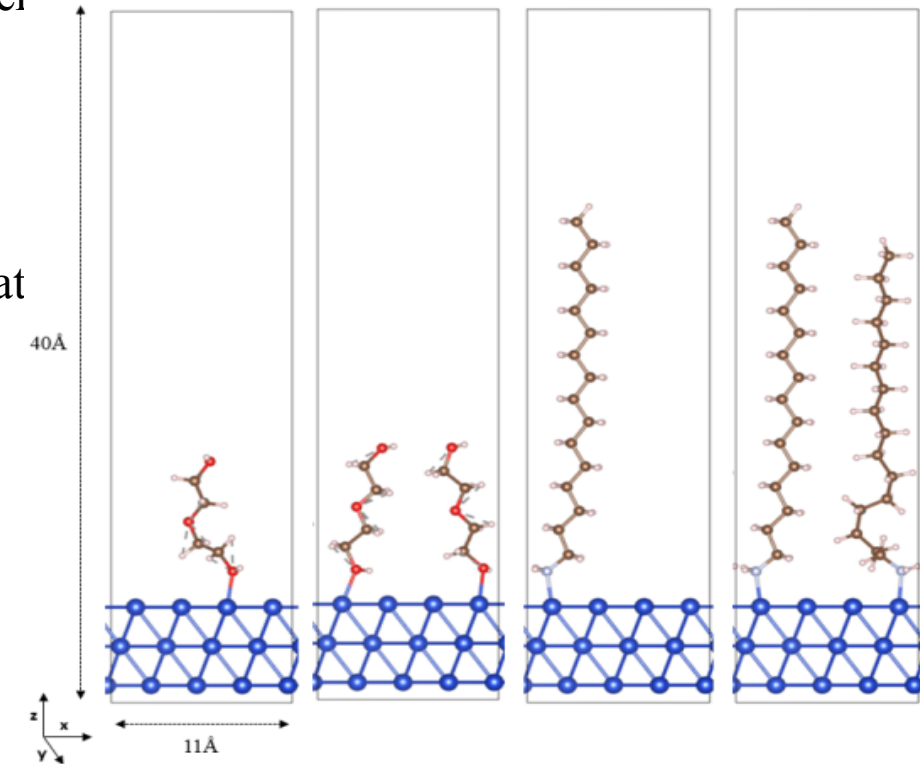


Figure 5. DFT structural models for (111) Cu surface with either one or two DEG and HDA molecules. Colors: copper (royal blue), carbon (grey), oxygen (red), hydrogen (white), nitrogen (light blue).

Periodic DFT Explains Synergistic Surfactant Oxidation Performance of Cu-NPs



- With any surfactant present, a clear increase in BE is observed when the H₂O molecules need to pass through the surfactant to access the surface, an effect which was more clear on the Cu(111) surfaces with higher surfactant concentration.
- For example for the Cu(111) surface with 0.2 HDA/nm² there was a increase in binding energy by ~0.2 eV, when the water molecule passes the surfactant molecule (~15 Å from the surface).
- ✓ While this only represents an initial investigation into the HDA/DEG terminated Cu(111) surface, it does demonstrate that there is some interaction between the HDA/DEG that is protective of bare Cu surfaces in the presence of water.
- ✓ Overall, the water molecules bound more strongly to the bare Cu(111) surface than to the surface with the surfactant present, with energy penalties between 0.03-0.36 eV.

Table 2: Binding energy (eV) between the surfactant (HDA/DEG) and the Cu(111) surface and in the presence of water.

Surfactant	Concentration (#/nm ²)	
		H ₂ O to Cu (111)+Surfactant
DEG	0.1	-1.25
	0.2	-1.51
HDA	0.1	-1.30
	0.2	-1.06

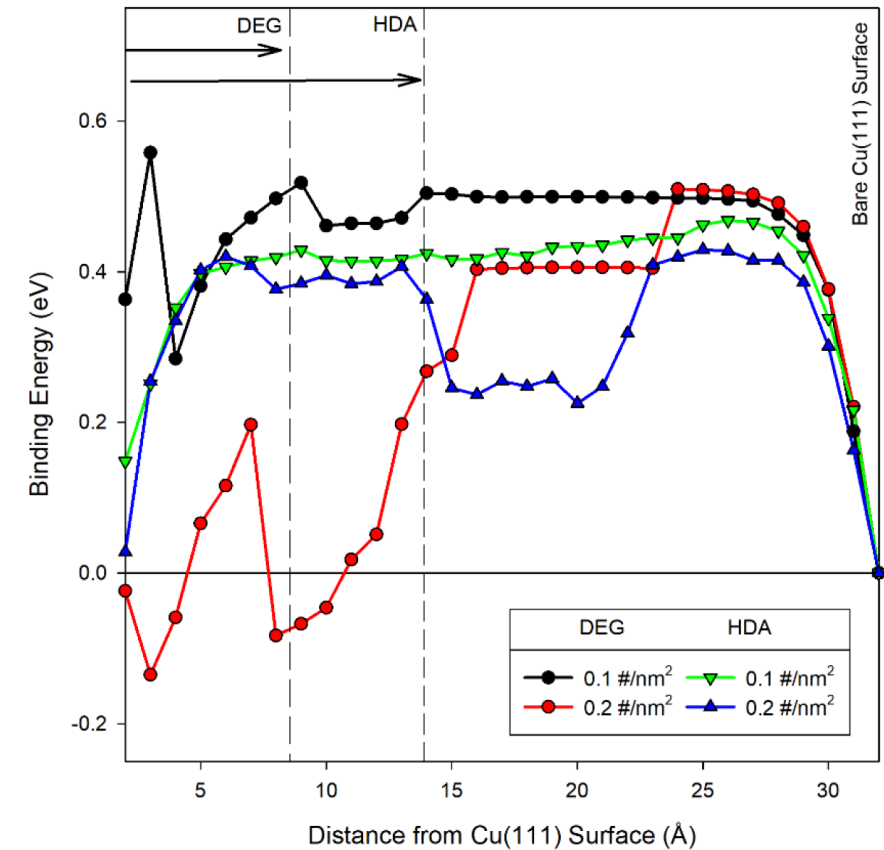
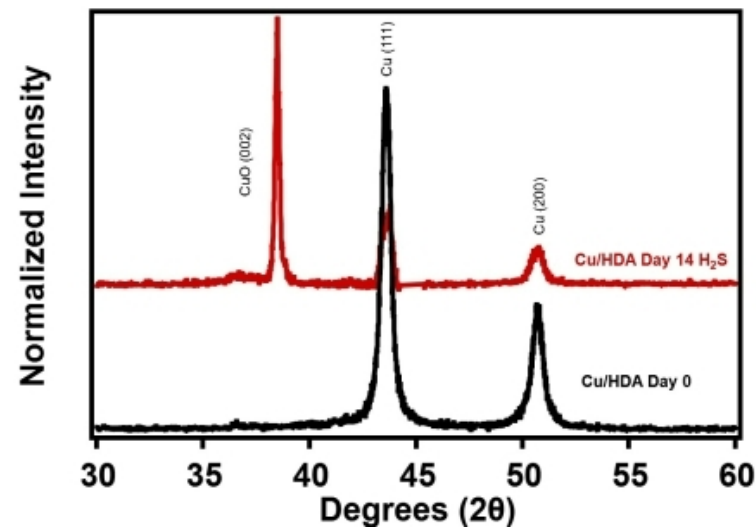
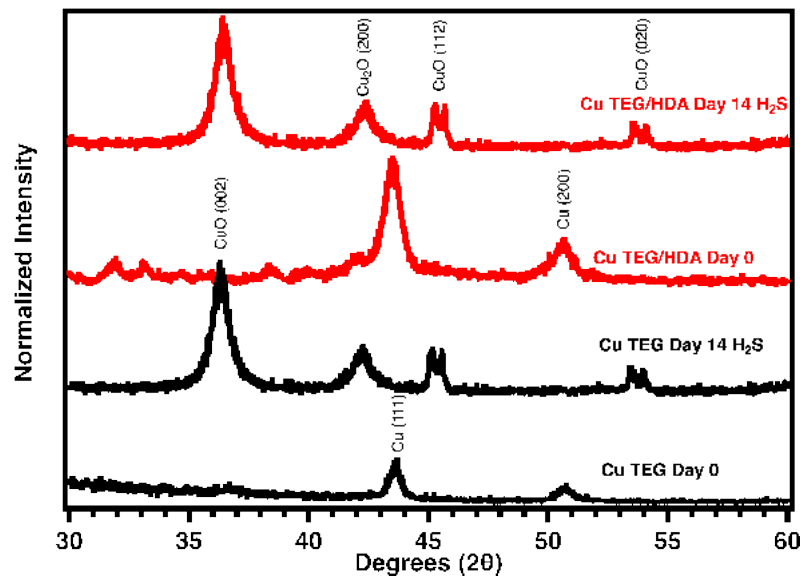
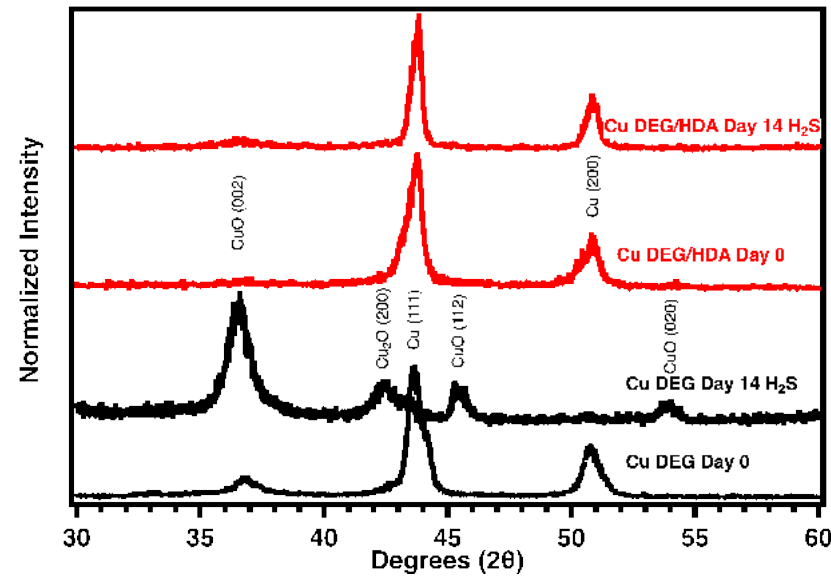
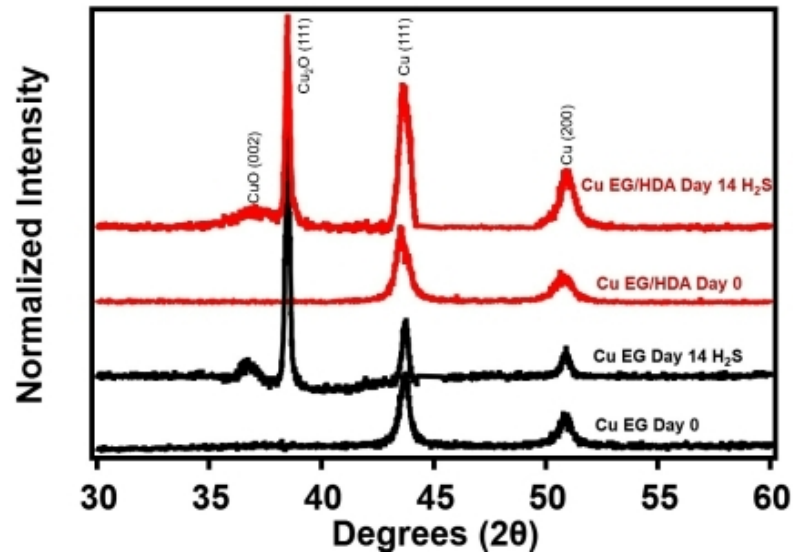


Figure 6. Binding energy (eV) of water with a Cu(111) with either 0.1 #/nm² or 0.2 #/nm² surfactant molecules bound to the surface.

Cu-NP in 10 ppm H₂S/50% RH Environment for 14 Days



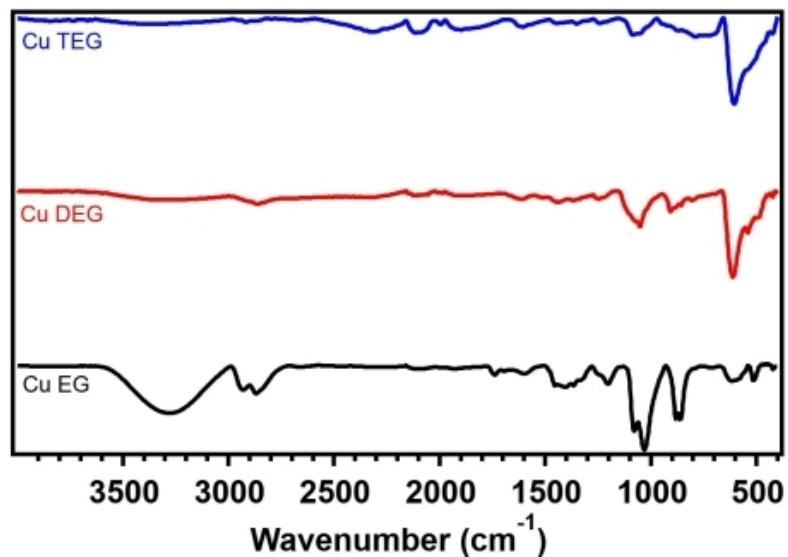
GES System for Environmental Testing

Sample	Cu %
Cu DEG	20
Cu DEG/HDA	77.6
Cu TEG	25.1
Cu TEG/HDA	46.6
Cu/HDA	33

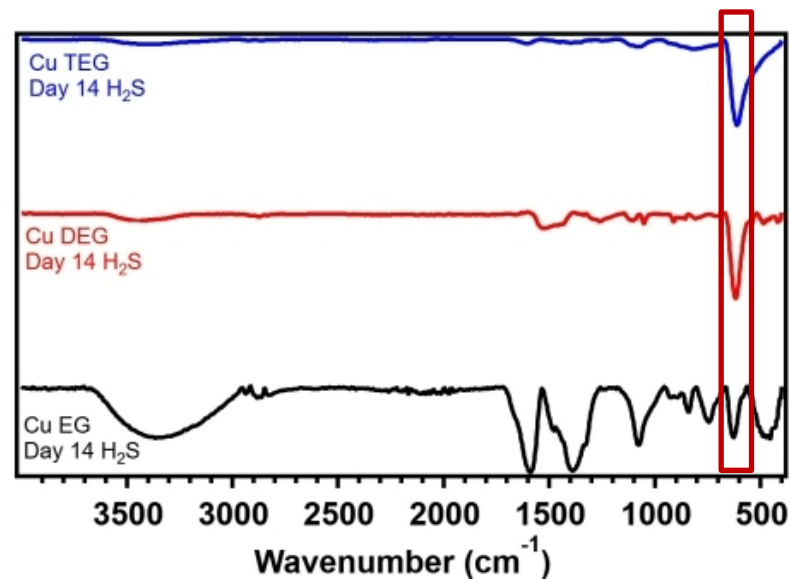
FTIR of Cu-NPs after H₂S Exposure



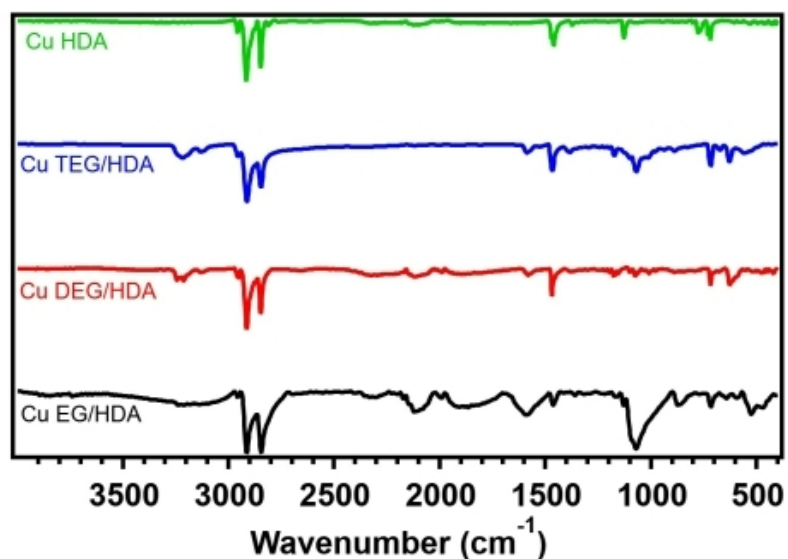
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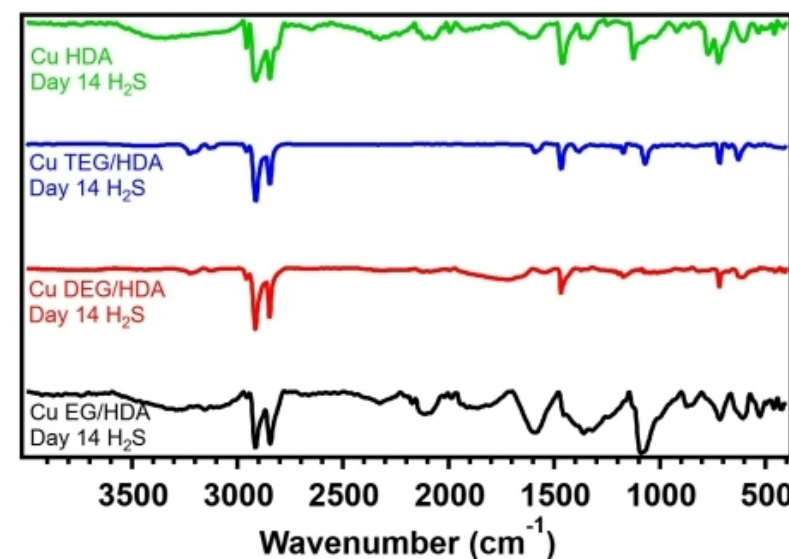
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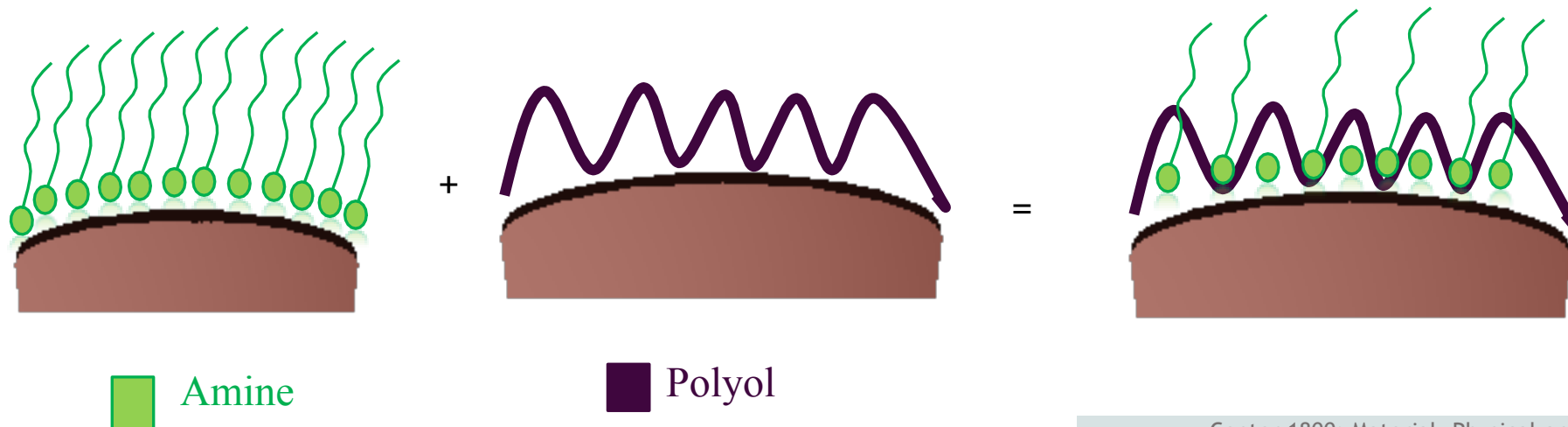


- Glycol-Cu-NPs show strong peaks near 600 cm⁻¹, which are associated with Cu-O bonding (denoted by red box).
- Their increase in intensity over time supports oxidation of the Cu NP surface.
- This peak behavior isn't seen in polyol/HDA particles.

Conclusion



- ✓ A novel Cu-NP synthesis recipe via a microwave-assisted polyol method at was developed.
- ✓ This recipe was also modified to synthesize oxidation-resistant Cu nanoparticles via the addition of HDA during the synthesis procedure.
- ✓ FTIR & TGA show the surface chemistry of the Cu-NPs indicating both species being present.
- ✓ The synergistic effects between the coating performance of the polyol and the hydrophobic properties of HDA leads to exceptional overall oxidation resistance in harsh environments.
- ✓ While O_2 adsorption on (111) oriented fcc Cu surface is thermodynamically favorable, amines have been shown to have an exceptional affinity to the same (111) surfaces.
- ✓ Overall, cost effective, oxidation-resistant copper nanoparticles were able to be quickly synthesized and efficiently.



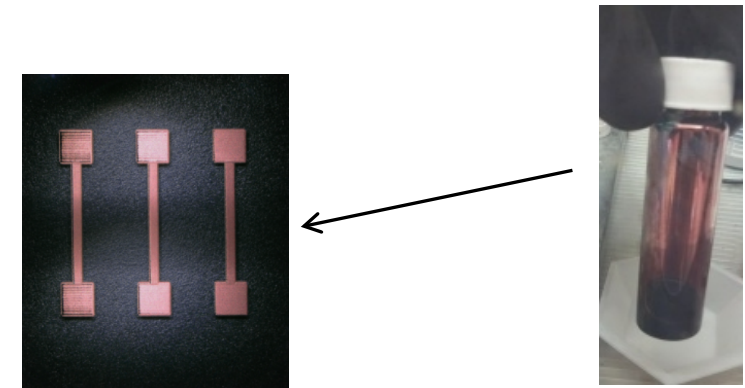
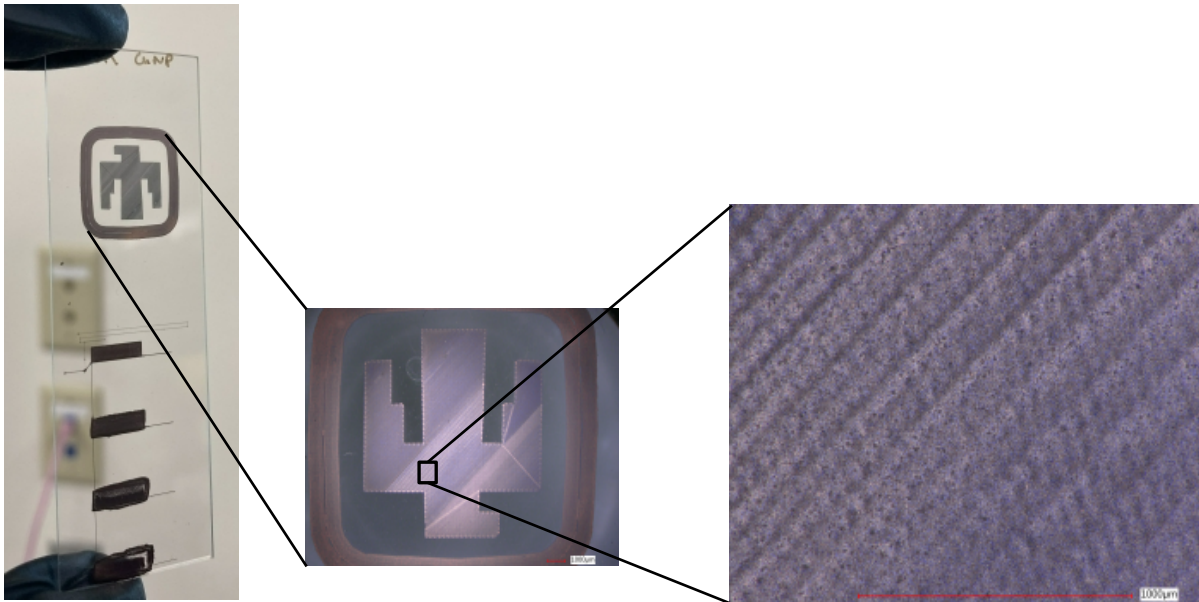
Future Work

Goal:

- Printable and conductive ink with homogenous distribution
- Easily dispersed in solution
- Able to be sintered

Current Status:

- Able to aerosoljet print Cu NP inks
- Currently optimizing ink performance to be comparable to bulk Cu
- Best performing ink is 54x bulk Cu





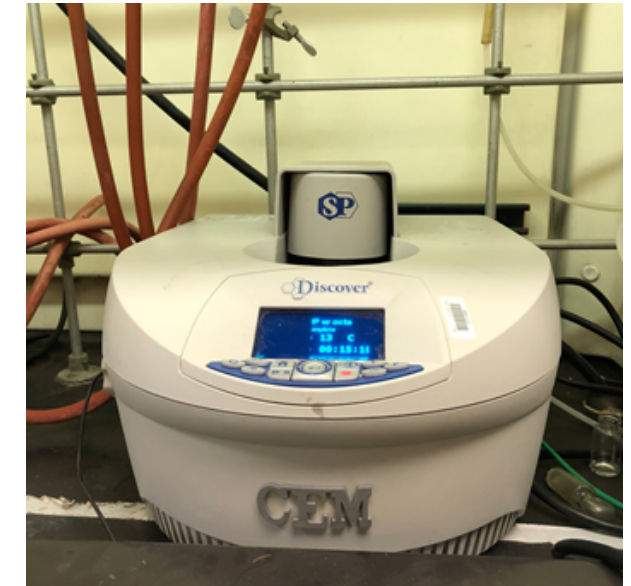
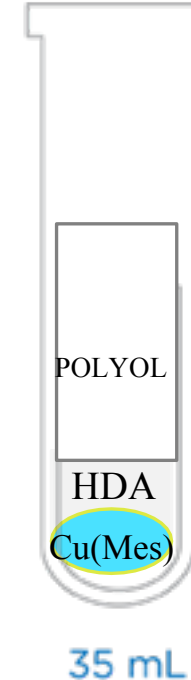
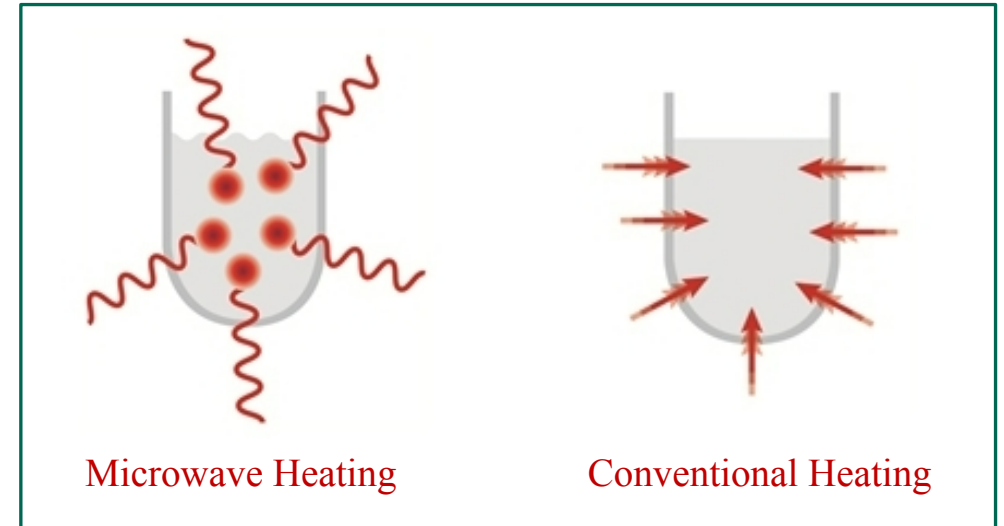
QUESTIONS?

Microwave Synthetic Route for Cu NP Production



Benefits of microwave heating:

- Direct interaction with materials
- Increased reaction rate
- Milder reaction conditions
- Greater chemical yield
- Rapid synthesis
- Uniform heating



35 mL

Procedure:

1. Add 1 g of Cu(Mes) to vial
2. Add 3 g of hexadecylamine to vial, opt.
3. Add 20 mL of polyol solvent
4. Select "Cu NP" program on CEM Discover microwave

FTIR of Pure Glycols

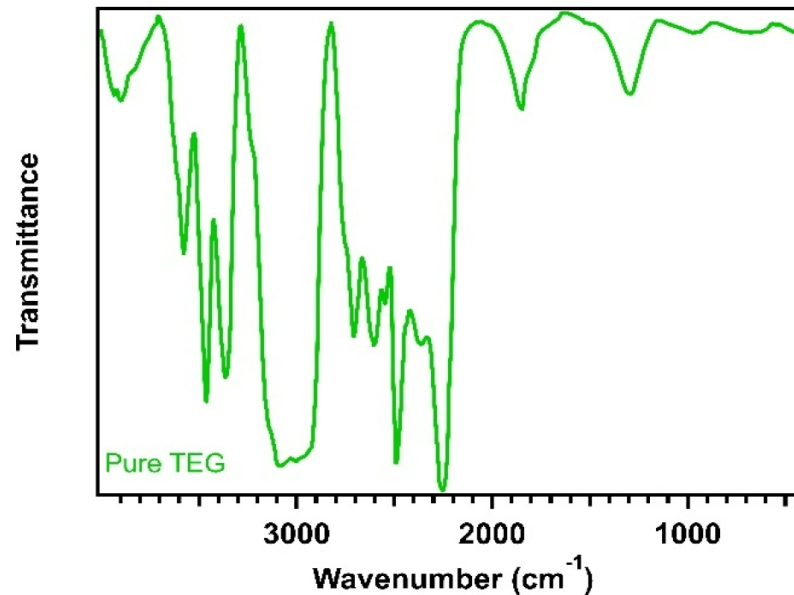
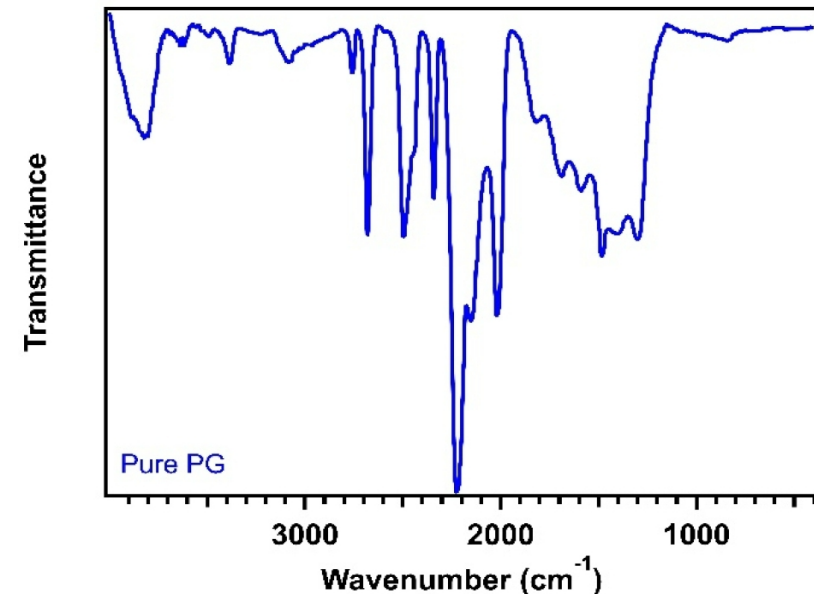
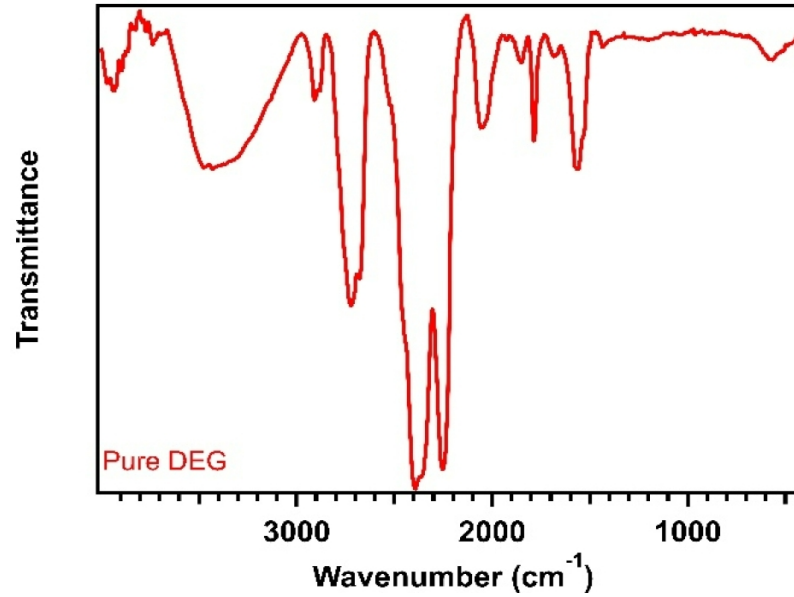
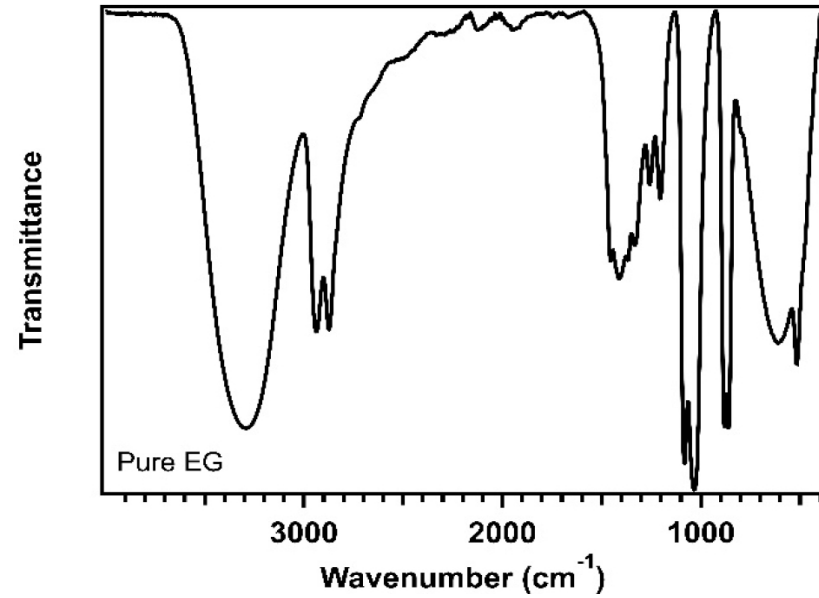


Figure A2. FTIR spectra of pure ethylene glycol (EG), pure diethylene glycol (DEG), pure propylene glycol (PG), and pure tetraethylene glycol (TEG).

TGA of Pure Glycols and HDA

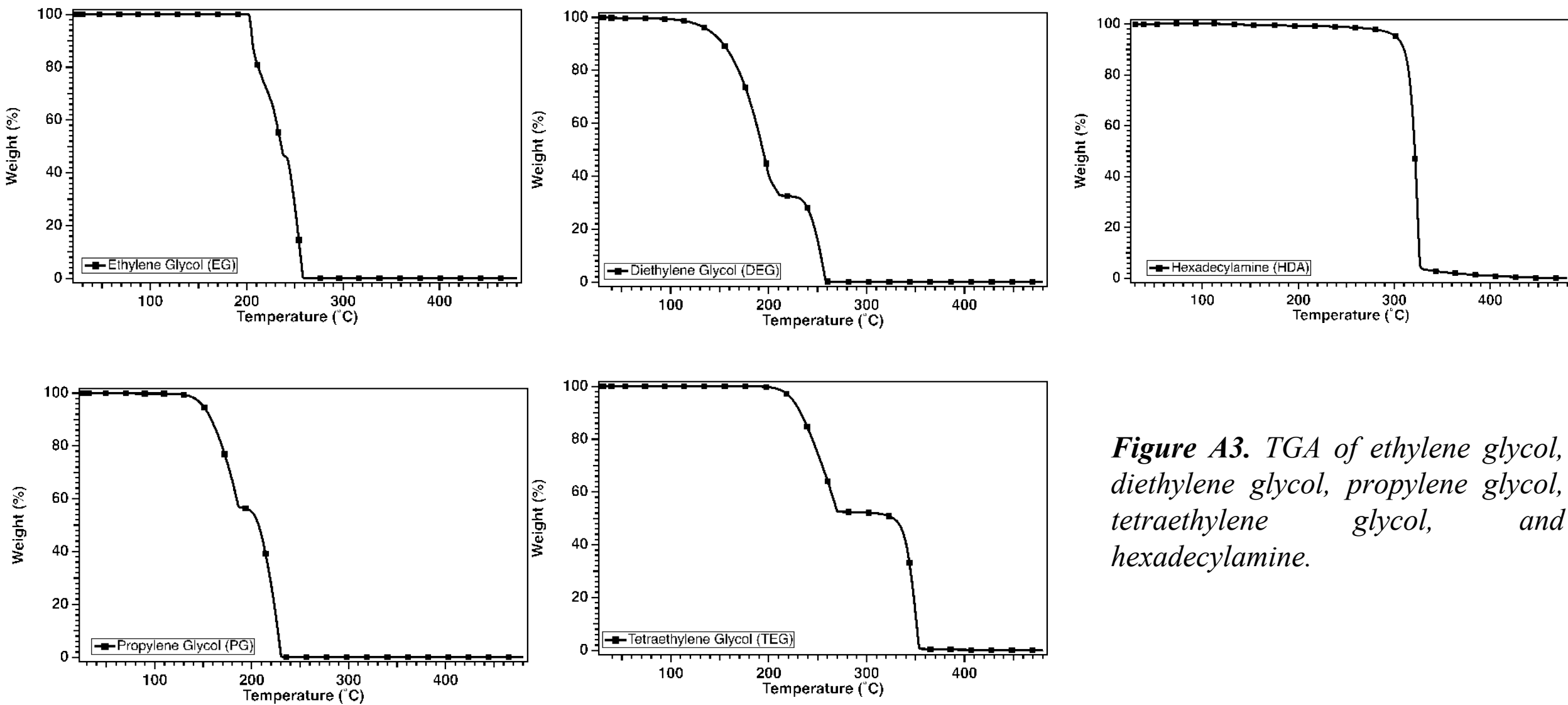


Figure A3. TGA of ethylene glycol, diethylene glycol, propylene glycol, tetraethylene glycol, and hexadecylamine.

FTIR of Glycol vs. Glycol/HAD After 14 Days in H₂S

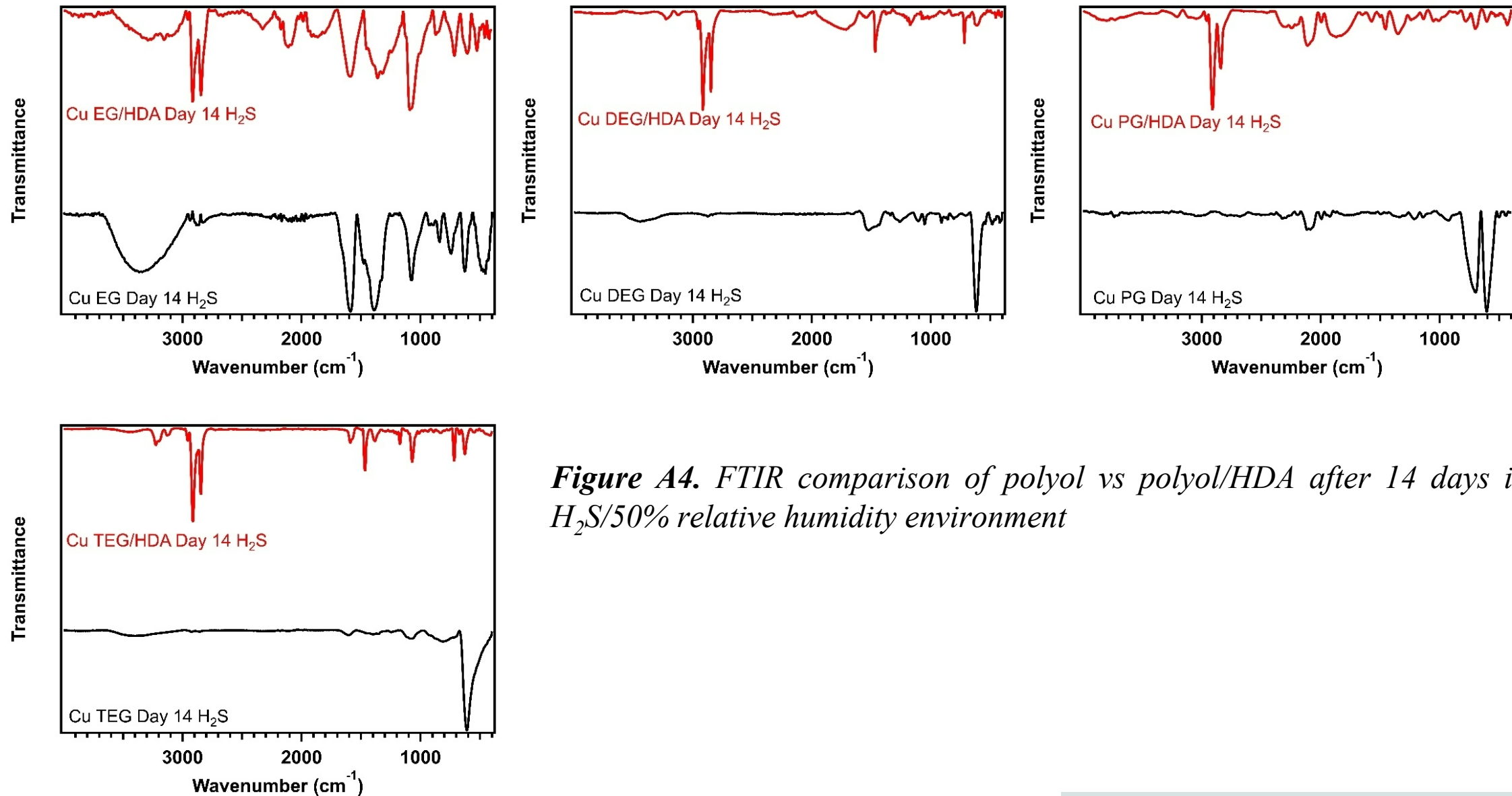


Figure A4. FTIR comparison of polyol vs polyol/HDA after 14 days in 10 ppm H₂S/50% relative humidity environment

FTIR of Pure EG & Pure HDA Before & After H₂S Exposure

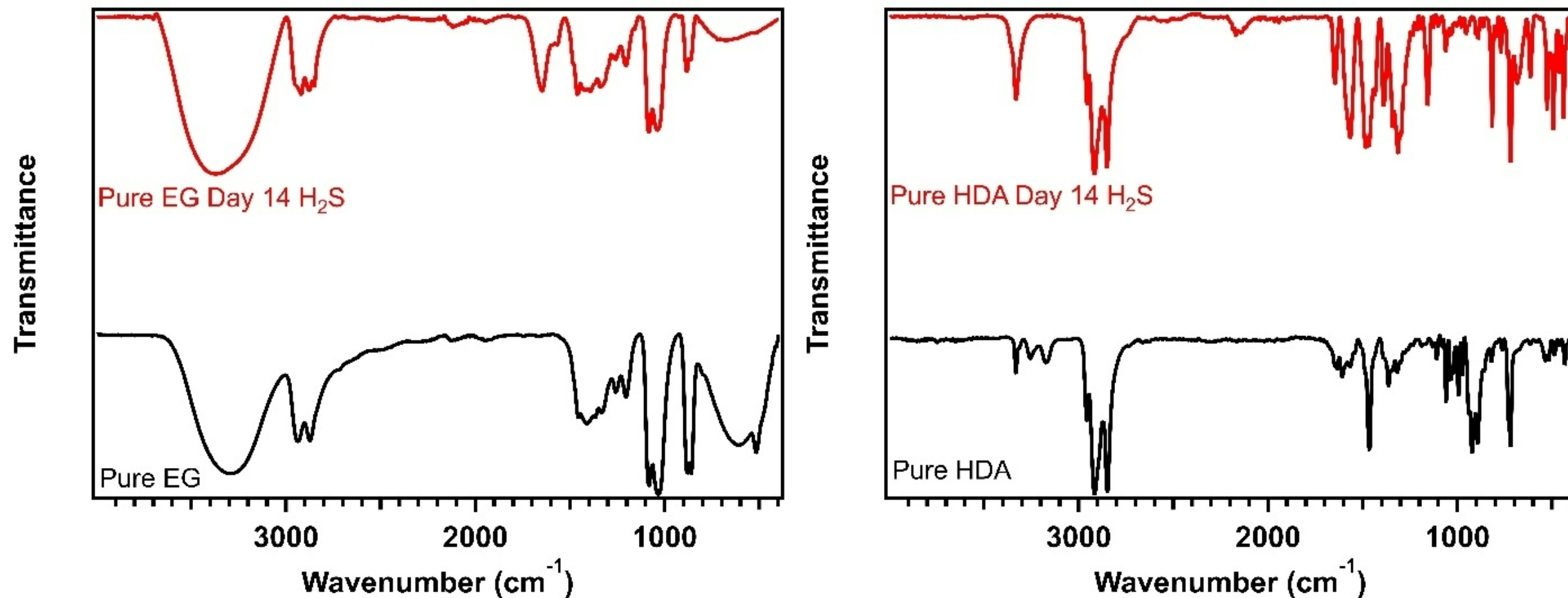


Figure A5. FTIR spectra of (a) pure ethylene glycol and (b) pure hexadecylamine before and after exposure to 10 ppm H₂S/50% RH.